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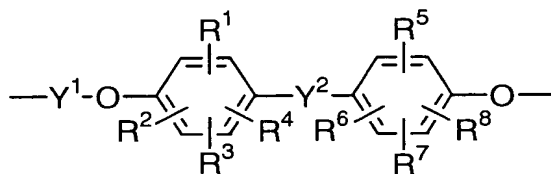
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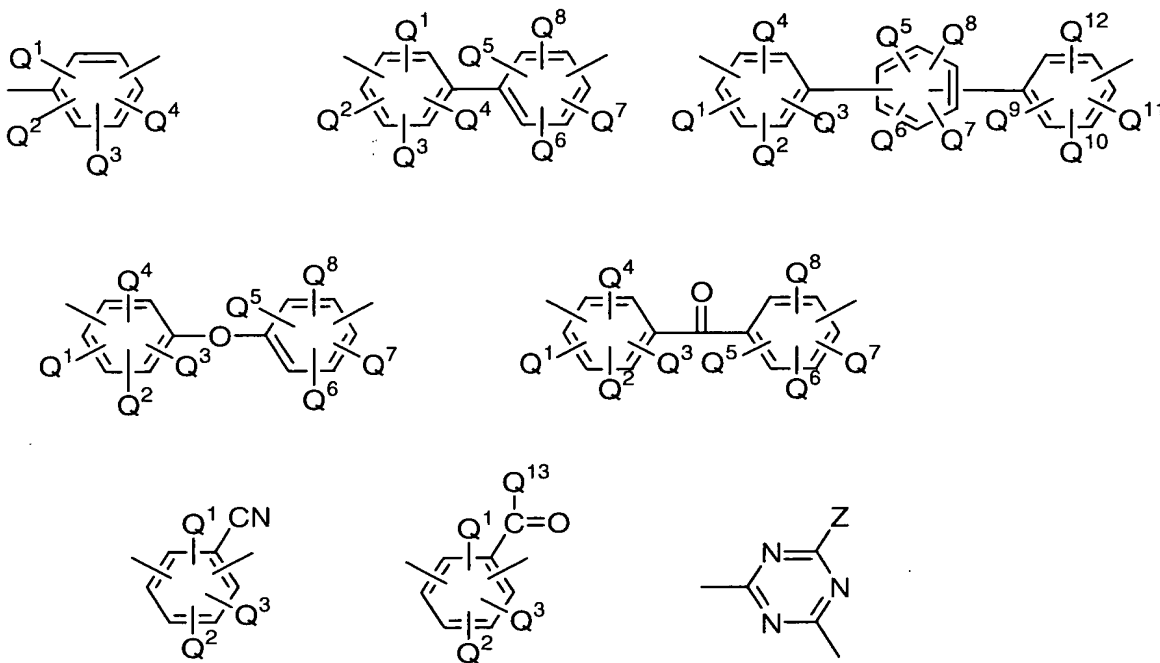
1. A polyether copolymer comprising (A) an aromatic polyether block and (B) an aliphatic polyether block.
2. The polyether copolymer according to claim 1, wherein (B) an aliphatic polyether block is on a side chain of (A) an aromatic polyether block.
3. The polyether copolymer according to claim 1, wherein the aromatic polyether block (A) has a structural unit represented by the following formula (1):



(1)

wherein  $R^1$ ,  $R^2$ ,  $R^3$ ,  $R^4$ ,  $R^5$ ,  $R^6$ ,  $R^7$  and  $R^8$  are independently selected from the group consisting of a hydrogen atom, a chlorine atom, an iodine atom, an alkyl group having 1 to 10 carbon atoms, an alkenyl group having 2 to 10 carbon atoms, an alkynyl group having 2 to 10 carbon atoms, a cycloalkyl group having 4 to 10 carbon atoms, a methoxy group, an ethoxy group, a phenyl group which may be substituted and a functional group represented by the formula (2) or (3) described below;  $Y^1$  is selected from any one of functional groups described below or two or more

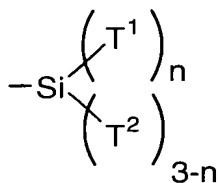
of the functional groups;



Y<sup>2</sup> is selected from any one of a single bond, a hydrocarbon group having 1 to 20 carbon atoms, an ether group, a ketone group and a sulfone group or two or more of them; at least one of R<sup>1</sup>, R<sup>2</sup>, R<sup>3</sup>, R<sup>4</sup>, R<sup>5</sup>, R<sup>6</sup>, R<sup>7</sup> and R<sup>8</sup> or Q<sup>1</sup>, Q<sup>2</sup>, Q<sup>3</sup>, Q<sup>4</sup>, Q<sup>5</sup>, Q<sup>6</sup>, Q<sup>7</sup>, Q<sup>8</sup>, Q<sup>9</sup>, Q<sup>10</sup>, Q<sup>11</sup>, Q<sup>12</sup> and Q<sup>13</sup> in at least one unit structure contained in a molecular chain is selected from functional groups represented by the formula (3);

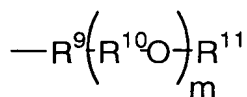
wherein Q<sup>1</sup>, Q<sup>2</sup>, Q<sup>3</sup>, Q<sup>4</sup>, Q<sup>5</sup>, Q<sup>6</sup>, Q<sup>7</sup>, Q<sup>8</sup>, Q<sup>9</sup>, Q<sup>10</sup>, Q<sup>11</sup> and Q<sup>12</sup> are independently selected from the group consisting of a hydrogen atom, an alkyl group having 1 to 10 carbon atoms, an alkenyl group having 2 to 10 carbon atoms, an alkynyl group having 2

to 10 carbon atoms and a functional group represented by the formula (2) or (3) described below;  $Q^{13}$  is selected from the group consisting of an alkyl group having 1 to 10 carbon atoms, an alkenyl group having 2 to 10 carbon atoms, an alkynyl group having 2 to 10 carbon atoms and a functional group represented by the formula (2) or (3) described below; Z is selected from the group consisting of a hydrogen atom, a fluorine atom, a chlorine atom, a bromine atom, an iodine atom, a group  $-OZ^1$  and a group  $-NZ^2Z^3$ ; and  $Z^1$ ,  $Z^2$  and  $Z^3$  are independently selected from the group consisting of a hydrogen atom, a saturated or unsaturated hydrocarbon group and an ether bond-containing group;



(2)

wherein  $T^1$  is selected from an alkenyl group having 2 to 10 carbon atoms;  $T^2$  is selected from an alkyl group having 1 to 10 carbon atoms and an aryl group; n represents an integer of 1 to 3 inclusive; plural  $T^1$ 's may be different from each other and plural  $T^2$ 's may also be different from each other;



(3)

wherein  $R^9$  is selected from a single bond and a hydrocarbon group having 1 to 10 carbon atoms;  $R^{10}$  is selected from a hydrocarbon group having 1 to 10 carbon atoms;  $R^{11}$  is selected from a hydrogen atom and a hydrocarbon group having 1 to 10 carbon atoms; and  $m$  is selected from an integer of 1 or more.

4. The polyether copolymer according to claim 3, wherein  $R^{10}$  is  $-CH_2-CH_2-$ ,  $-CH_2-CH(CH_3)-$  or  $-CH(CH_3)-CH_2-$ .

5. The polyether copolymer according to claim 1, wherein the relation between the thermal decomposition starting temperature  $T_a$  ( $^{\circ}C$ ) of the aromatic polyether block (A) and the thermal decomposition starting temperature  $T_b$  ( $^{\circ}C$ ) of the aliphatic polyether block (B) is represented by the formula:  
 $T_a \geq (T_b + 40)$ .

6. A process for producing a polyether copolymer according to claim 1, wherein the process comprises reacting a bisphenol compound corresponding to the material for a moiety of the aromatic polyether block (A), a di-halogenated compound and an aliphatic polyether having an OH group at the terminal and corresponding to the material for a moiety of the aliphatic polyether block (B) in the presence of an alkali.

7. The process according to claim 6, wherein a pre-reaction

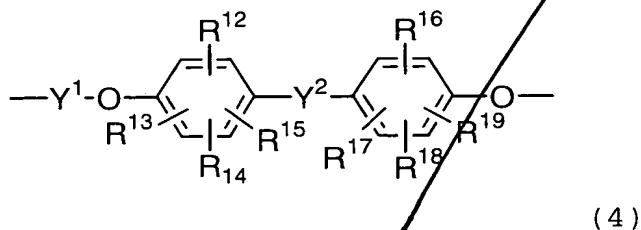
of the di-halogenated compound and the aliphatic polyether having an OH group at the terminal is carried out in the presence of an alkali, then the bisphenol compound and the di-halogenated compound are added to the reaction mixture and the reaction is continued in the presence of an alkali.

8. A process according to claim 1, wherein the process comprises steps of metallizing an aromatic polyether corresponding to a moiety of (A), and carrying out a substitution reaction with a halide of an aliphatic polyether corresponding to a moiety of (B).

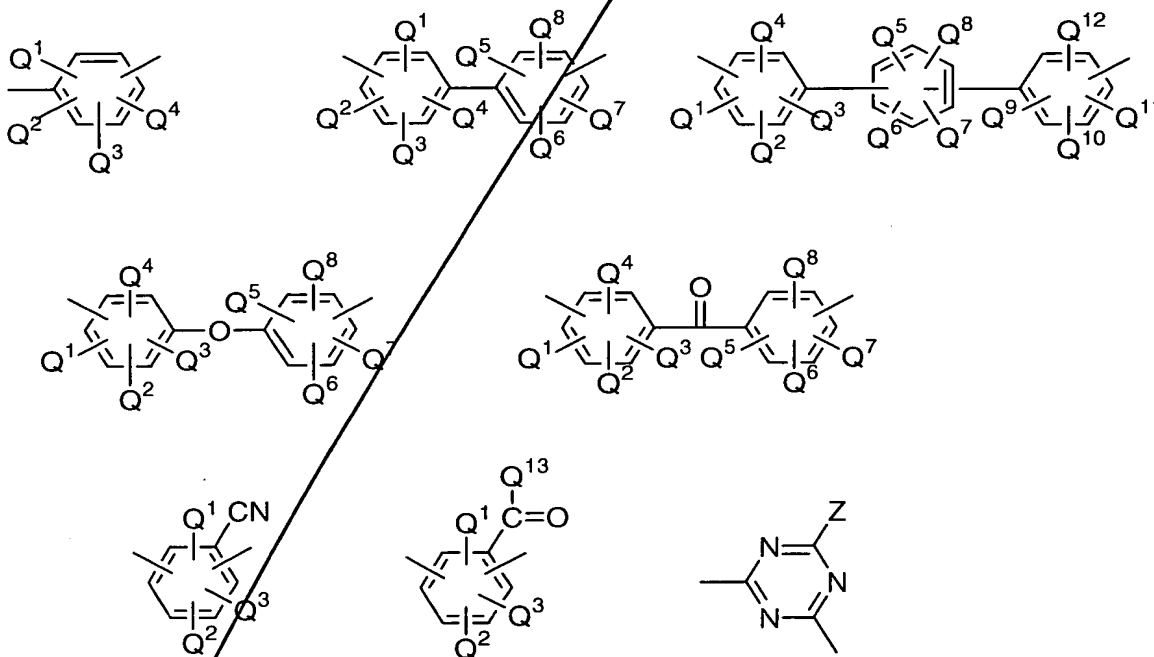
9. A coating solution for forming a porous organic film comprising (a) a polyether copolymer according to claim 1 and (b) an organic solvent.

10. A coating solution for forming a porous organic film comprising (c) a resin having a thermosetting functional group, in addition to (a) and (b) according to claim 9.

11. The coating solution according to claim 10, wherein the resin having a thermosetting functional group (c) has a unit structure represented by the following formula (4):



wherein  $R^{12}$ ,  $R^{13}$ ,  $R^{14}$ ,  $R^{15}$ ,  $R^{16}$ ,  $R^{17}$ ,  $R^{18}$  and  $R^{19}$  are independently selected from the group consisting of a hydrogen atom, a chlorine atom, an iodine atom, an alkyl group having 1 to 10 carbon atoms, an alkenyl group having 2 to 10 carbon atoms, an alkynyl group having 2 to 10 carbon atoms, a cycloalkyl group having 4 to 10 carbon atoms, a methoxy group, an ethoxy group, a phenyl group which may be substituted and a functional group represented by the formula (2) described above;  $Y^1$  is selected from any one of functional groups described below or two or more of the functional groups;



$Y^2$  is selected from any one of a single bond, a hydrocarbon group having 1 to 20 carbon atoms, an ether group, a ketone

group and a sulfone group or two or more of them; at least one of  $R^{12}$ ,  $R^{13}$ ,  $R^{14}$ ,  $R^{15}$ ,  $R^{16}$ ,  $R^{17}$ ,  $R^{18}$  and  $R^{19}$  or  $Q^1$ ,  $Q^2$ ,  $Q^3$ ,  $Q^4$ ,  $Q^5$ ,  $Q^6$ ,  $Q^7$ ,  $Q^8$ ,  $Q^9$ ,  $Q^{10}$ ,  $Q^{11}$ ,  $Q^{12}$  and  $Q^{13}$  in at least one unit structure contained in a molecular chain is selected from an alkenyl group having 2 to 10 carbon atoms, an alkynyl group having 2 to 10 carbon atoms and a functional group represented by the formula (2) described above;

wherein  $Q^{14}$ ,  $Q^{15}$ ,  $Q^{16}$ ,  $Q^{17}$ ,  $Q^{18}$ ,  $Q^{19}$ ,  $Q^{20}$ ,  $Q^{21}$ ,  $Q^{22}$ ,  $Q^{23}$ ,  $Q^{24}$  and  $Q^{25}$  are independently selected from the group consisting of a hydrogen atom, an alkyl group having 1 to 10 carbon atoms, an alkenyl group having 2 to 10 carbon atoms, an alkynyl group having 2 to 10 carbon atoms and a functional groups represented by the formula (2) described above;  $Q^{26}$  is selected from the group consisting of an alkyl group having 1 to 10 carbon atoms, an alkenyl group having 2 to 10 carbon atoms, an alkynyl group having 2 to 10 carbon atoms and a functional group represented by the formula (2) described above; and  $Z$ ,  $Z^1$ ,  $Z^2$  and  $Z^3$  have the same meaning as described claim 3.

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12. The coating solution according to claim 10, wherein the thermal curing reaction starting temperature  $T_c$  of the resin having a thermosetting functional group (c) is less than the thermal decomposition starting temperature  $T_b$  of the aliphatic polyether block (B).

13. The coating solution according to claim 9, wherein the organic solvent (b) comprises a solvent having an aromatic



ring in its molecule and having a boiling point of 250°C or below.

14. The coating solution according to claim 9, wherein the organic solvent (b) comprises at least one selected from the group consisting of anisole, phenetole and dimethoxybenzene.

15. A process for forming a porous organic film, wherein the process comprises coating a substrate with a coating solution for forming a porous organic film according to claim 9, and carrying out a heat treatment to generate a void at a temperature of not less than the thermal decomposition starting temperature  $T_b$  of an aliphatic polyether block and at a temperature of less than the thermal decomposition starting temperature  $T_a$  of an aromatic polyether block.

16. A process for forming a porous organic film, wherein the process comprises coating a substrate with a coating solution for forming a porous organic film according to claim 10, then thermally curing the film at a temperature of not less than the thermal curing reaction starting temperature  $T_c$  of a resin having a thermosetting functional group and at a temperature of less than the thermal decomposition starting temperature  $T_b$  of an aliphatic polyether block, and carrying out a heat treatment to generate a void at a temperature of not less than the thermal decomposition starting temperature  $T_b$  of an aliphatic polyether block and at a temperature of less than

